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Assignment 9

EAS 504: Applications of Data Science - Industrial Overview - Spring 2023

Lecture by Arun Venkatachar and Sashi Obilisetty on Data Science in the Electronic Design Automation (EDA) Industry

Q1): Describe the market sector or sub-space covered in this lecture.

Ans: This lecture will examine the market sector or sub-space of Electronic Design Automation Industry (EDA) and how Machine learning is used in Electronic Design Automation Industry (EDA). A single chip has billions of transistors, allowing for higher computing power, improved energy efficiency, and expanded functionality in electronic devices. The capacity to pack so many transistors on a chip has transformed the world of electronics and enabled the development of complex and powerful electronic gadgets that we use every day. EDA firms provide consultancy and support services to electronic design teams, assisting them in optimizing their design flows, troubleshooting difficulties, and overcoming design obstacles. This may involve offering technical assistance, training, and instruction on how to use EDA tools successfully and efficiently. EDA design verification and validation procedures can benefit from ML approaches. ML algorithms, for example, may examine simulation and test data to find design mistakes, timing violations, and other difficulties. ML-based verification and validation methodologies can aid in the early identification and resolution of design difficulties, lowering the risk of design failures and enhancing product reliability. To uncover design mistakes, timing violations, and other concerns, machine learning methods can be employed to examine simulation and test data. Data-driven verification and validation methodologies aid in the early identification and resolution of design issues, lowering the risk of design failures and enhancing product reliability.

Q2): What data science related skills and technologies are commonly used in this sector?

Ans: APIs and machine learning capabilities and technologies are widely employed in the EDA business for circuit design, verification, and optimization activities. Design automation, flaw detection, design optimization, and data analysis are examples of these. In the EDA industry, APIs and machine learning are frequently employed for data analysis activities. Machine learning techniques, for example, may be used to evaluate enormous datasets of design, simulation, and measurement data to extract insights and make educated design decisions. For effective data processing and analysis, APIs may be utilized to incorporate these data analysis algorithms with electronic design tools. APIs and machine learning may be used to optimize numerous parts of the electrical design process, including power, area, and performance optimization. Keras is a deep learning API that makes it easier to build neural networks. It is also more efficient because

it supports CUDA Nvidea, allowing you to train your deep learning model more quickly. Machine learning algorithms, for example, may examine enormous amounts of design data to uncover optimization possibilities and provide improved design solutions. To allow automated design optimization, APIs may be utilized to implement these optimization methods in electrical design tools.

Q3): How are data and computing related methods used in typical workflows in this sector? Illustrate with an example.

Ans: Electronic Design Automation (EDA) relies heavily on data and computing-related technologies for developing and producing electrical circuits and systems. Data from multiple sources is collected and processed to obtain insights for design synthesis, verification, optimization, validation, and production. To optimize the design process, machine learning techniques may be integrated into these methodologies. To achieve design parameters, design synthesis includes creating and optimizing circuit topologies, component locations, and routing possibilities. Machine learning algorithms can examine previous design data to guide the synthesis process and provide more efficient designs. Design verification activities including simulation, emulation, and formal verification guarantee that the design fulfills specifications. Emulation generates a replica for more accurate testing, whereas simulation examines the design's performance, functionality, and dependability. To show the validity of a design, formal verification employs mathematical techniques. The usage of CMLP APIs in the EDA sector has various advantages. For starters, it encourages interoperability across EDA tools from various manufacturers, letting designers employ best-of-breed tools at various points of the design process. Because designers are not limited to adopting a single vendor's toolchain, this supports competition and innovation in the EDA sector. Validation activities verify that the design is ready for production. In the manufacturing phase, data and computing-related approaches are employed for process planning, yield optimization, and quality control.

Q4): What are the data science related challenges one might encounter in this domain?

Ans: Through iterative design and production cycles, chip makers are always working to optimize the chip's performance, power consumption, and other aspects. This may entail upgrading the chip's layout, materials, manufacturing methods, and other elements to improve the chip's capabilities and match the increasing smartphone market needs. EDA processes frequently require the use of many tools and data sources from various suppliers, each of which may utilize a different data format, standard, or protocol. Integrating and transferring data amongst EDA systems can be difficult and may include data transformation, mapping, or conversion. In EDA, achieving interoperability among many tools and data sources can be a considerable difficulty. EDA is a highly specialized subject that necessitates domain expertise to evaluate and analyze data-driven techniques' findings. To effectively use data science approaches, data scientists working in EDA must have a thorough grasp of electrical design ideas, tools, and procedures. It is also necessary for successful decision-making to interpret and communicate the outcomes of data-driven models to domain experts and stakeholders. It is vital to safeguard the confidentiality, integrity, and availability of design data to avoid data breaches, intellectual

property theft, and unauthorized access. In EDA processes, it is critical to include strong data security features like encryption, authentication, and access control.

Q5): What do you find interesting about the nature of data science opportunities in this domain?

<u>Ans</u>: The growing need for advanced electronic systems and technologies is driving considerable growth in the demand for silicon chips in a variety of sectors. The semiconductor sector, especially silicon chip demand, is critical to fueling and enabling innovation in modern industries and technology. With new technologies like sophisticated semiconductor processes, chip designs, packaging technologies, and system-level design techniques, the EDA domain is continually developing. Data scientists in EDA can collaborate with cutting-edge technology to provide data-driven solutions to solve developing difficulties and capitalize on new possibilities, such as the use of AI and machine learning in chip design, manufacturing, and testing. As data scientists create innovative solutions, tools, and approaches to solve the issues encountered by chip designers and manufacturers, the EDA domain provides chances for innovation and entrepreneurship. This can result in the formation of startups, spin-offs, or new product lines within current organizations, giving data scientists opportunities to contribute to the growth and development of the EDA industry.

(i) Describe some of the challenges in applying machine learning approaches to this domain (15 pts of the 80 C+R points in the rubric)

Ans: Due to data availability and quality, scalability and efficiency, design complexity and variability, interpretability and explainability, validation and verification, domain expertise and collaboration, as well as regulatory and ethical considerations, applying machine learning approaches to the EDA domain can be difficult. Overcoming these issues necessitates thorough evaluation of the EDA domain's particular requirements and limits, as well as the construction of strong and dependable machine learning models capable of efficiently addressing the special demands of EDA processes. A robust cooperation between data scientists, machine learning professionals, and domain experts with a comprehensive grasp of the EDA domain, its difficulties, and needs is required for successful machine learning application in EDA. Bridging the gap between machine learning knowledge and EDA domain expertise can be difficult since it necessitates efficient communication, cooperation, and integration of various skill sets. Validating and confirming the correctness and dependability of machine learning models can be difficult when using machine learning methodologies in EDA. It might be difficult to ensure that machine learning models are tested and verified to fulfill the demanding criteria of EDA designs.

(ii) Describe two illustrative use cases from this domain where ML approaches have been successfully used. (15 pts of the 80 C+R points in the rubric)

<u>Ans</u>: As chips get more sophisticated and advanced, identifying and diagnosing problems during manufacturing and raising yield rates become key hurdles in smartphone chip design. By exploiting data-driven methodologies, ML approaches have been effectively applied for defect diagnosis and yield enhancement. The physical design and placement of components in

integrated circuits (ICs) is an important phase in the chip design process. It entails establishing the best position, orientation, and interconnects for various components on the chip to meet desired performance metrics including area, power, and timing. By exploiting data-driven strategies, ML approaches have been effectively applied for physical design and placement jobs. ML models trained on vast datasets of chip layouts, performance measurements, and design rules, for example, may learn to anticipate the ideal location of components based on their properties, interconnects, and design restrictions. Floor planning, which includes putting big macroblocks on the chip to optimize space, power, and routing congestion, can also benefit from ML models.